

# Stitched Passive CMOS Strip Sensors

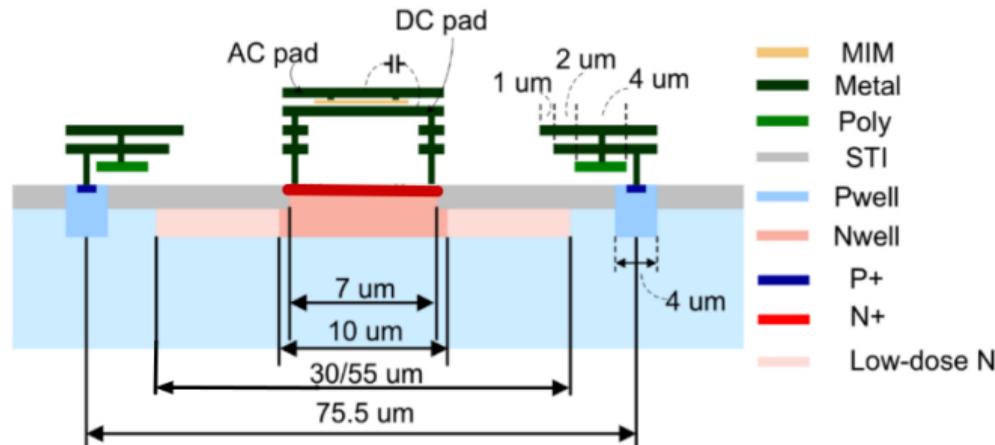
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Albert Ludwig University of Freiburg

40<sup>th</sup> RD50 Workshop, CERN, June 2022

# Stitched Passive CMOS Strip Sensors

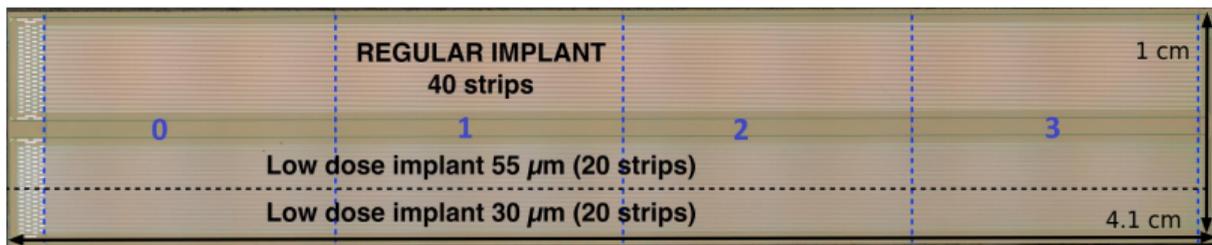
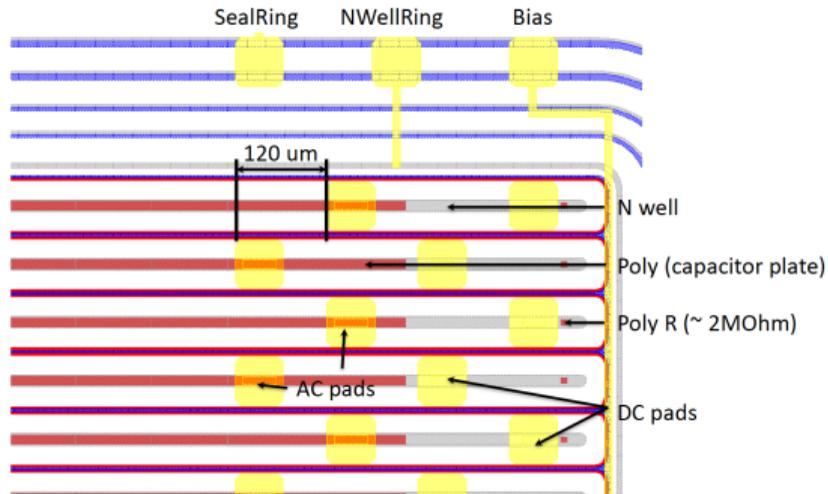
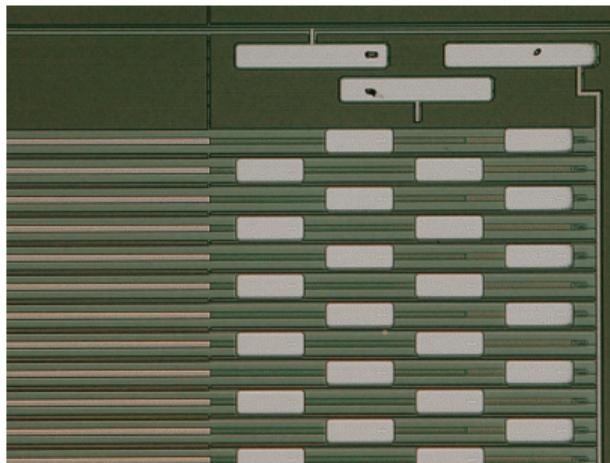
- L-Foundry 150 nm process
- float-zone silicon, 3-5 k $\Omega$  cm resistivity
- (150  $\pm$  10)  $\mu$ m thickness
- 40 strips with 75.5  $\mu$ m pitch
- 4.1  $\times$  1 cm<sup>2</sup> or 2.1  $\times$  1 cm<sup>2</sup>
- 3 designs in one unit:  
*Regular & Low Dose 30/55*



- frontside processing: reticle stitching with 1 cm<sup>2</sup> masks for larger areas
- backside processing: laser annealing, highly doped p<sup>+</sup> layer and add. metallization

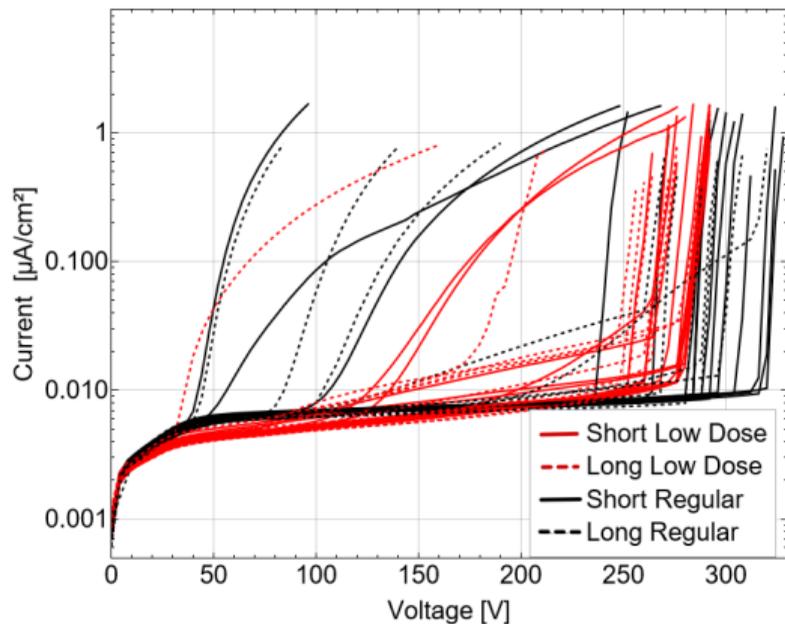


# Stitched Passive CMOS Strip Sensors

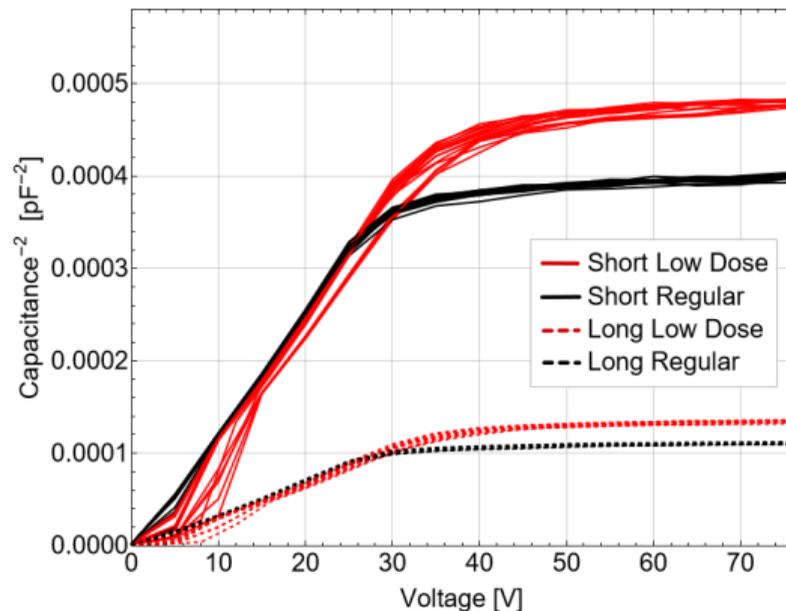


# IV & CV Measurements

IV

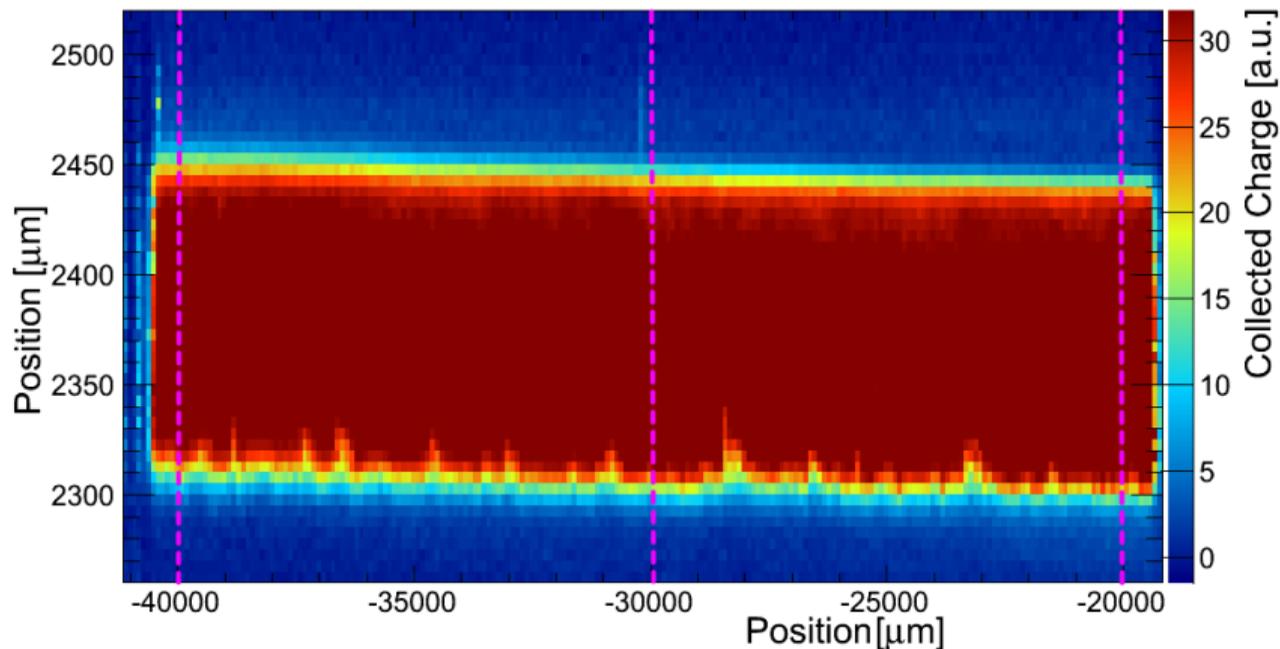


CV



- unirradiated sensors
- breakdown at  $\sim 250$  V, full depletion at  $\sim 30$  V
- second batch improved over first batch

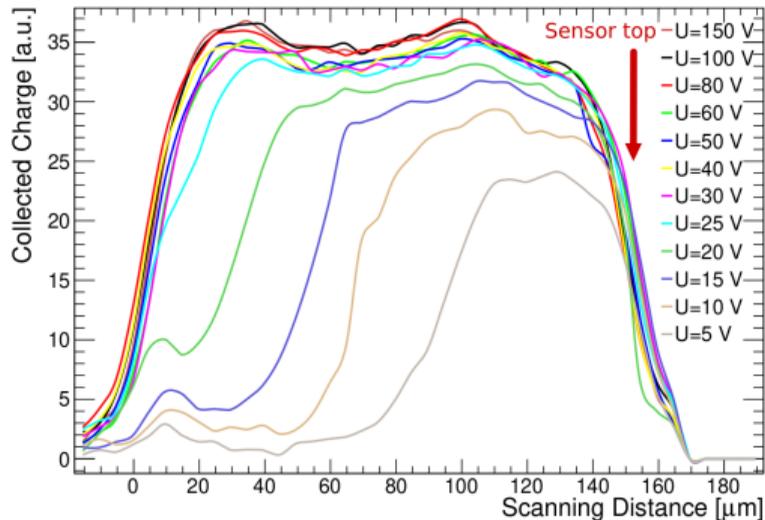
# Edge-TCT: 2D Scan



- unirradiated, short *LD30* sensor at 100 V (fully depleted)
- homogeneous charge collection (apart from scratches on edge of sensor)
- stitches not visible

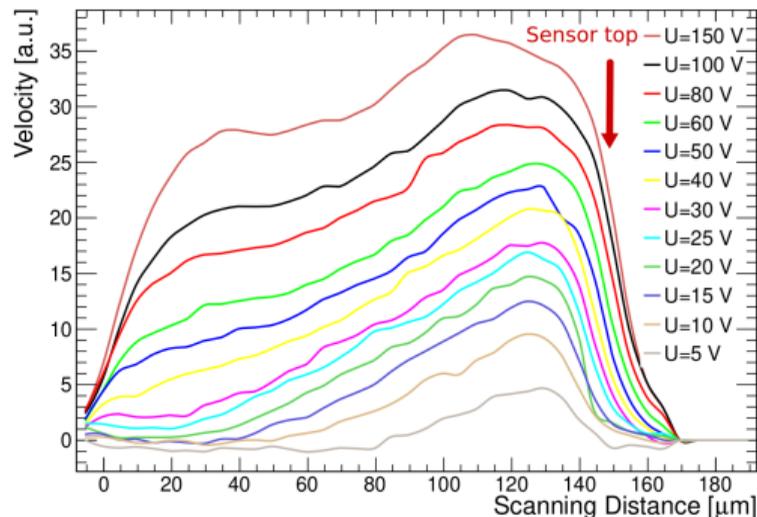
# Edge-TCT: Charge Collection & Electron Velocity

LD30



- sensors deplete top to back
- full depletion at 30-40 V
- complete sensor volume sensitive to charge
- collected charge remains constant after full depletion

LD30

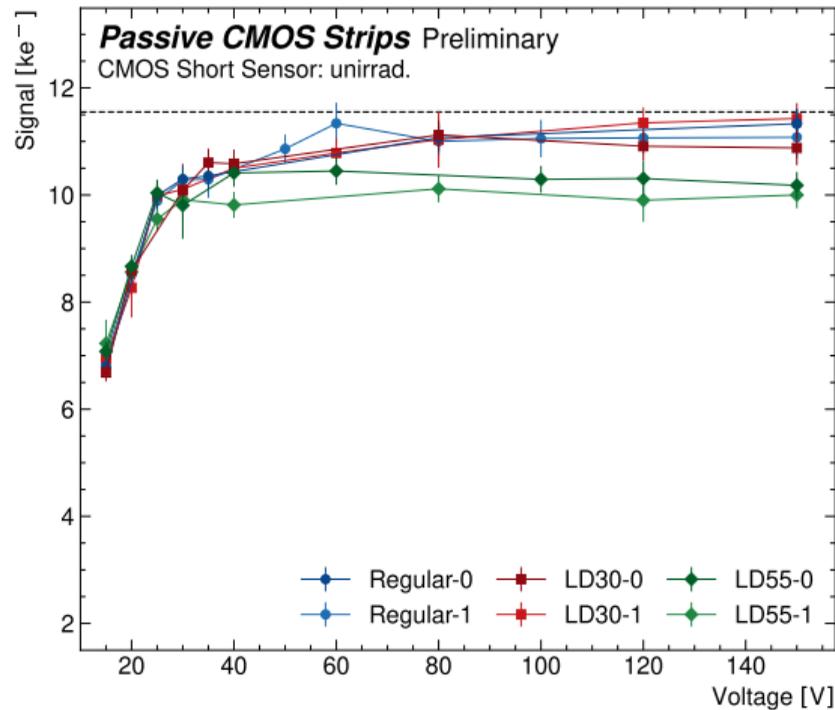


- velocity still increases after full depletion
- expected approx. triangular shape visible
- similar results for *Regular* design



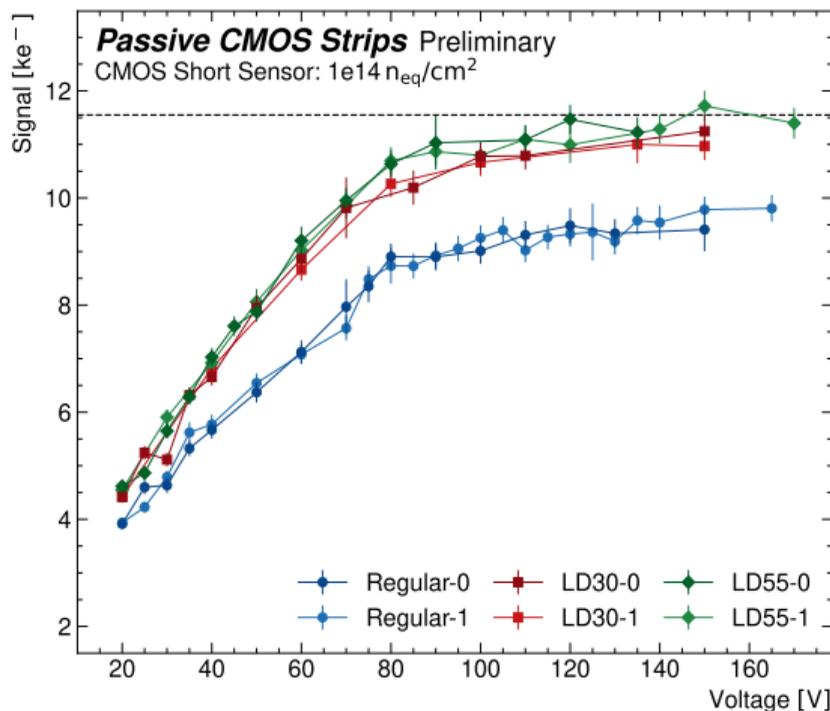
# Charge Collection: Short Sensor

- $^{90}\text{Sr}$   $\beta$ -decay source gives MIP-like  $e^-$  for charge creation in sensors
- unirradiated
- full depletion at  $\sim 40$  V
- constant signal after full depletion
- *Regular* and *LD30* reach expected charge of  $\sim 11.5 \text{ ke}^-$
- *LD55* systematically low charge  $\rightarrow$  *highest capacitance, maybe read-out electronics unable to handle it*
- no effect of stitching visible



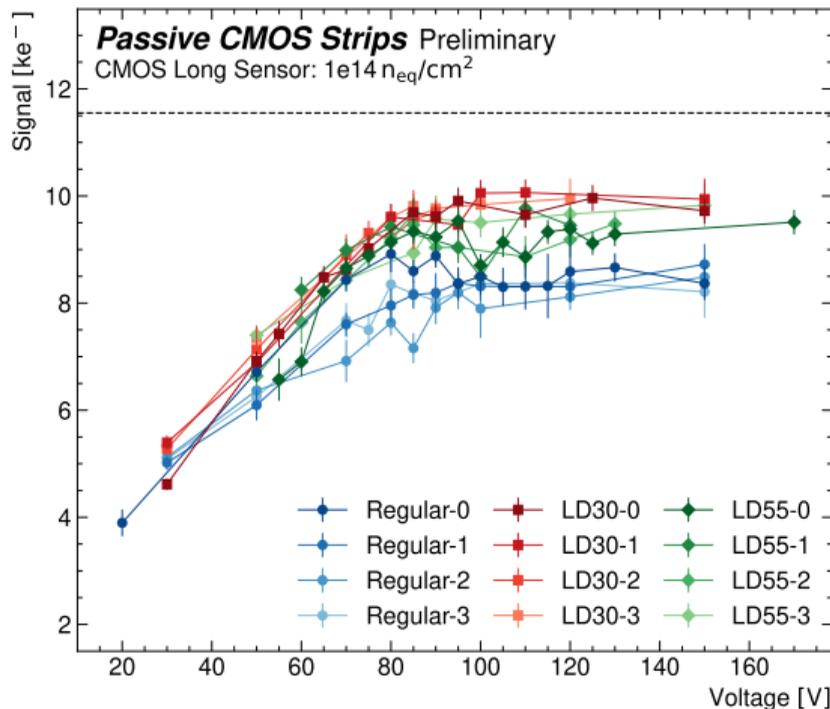
# Charge Collection: Short Sensor

- irradiated up to  $1 \cdot 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2$
- full depletion at  $\sim 80 \text{ V}$
- LD30/55 have suspiciously high charge  
→ *sensor specific measurement error?*
- Regular significantly less charge after irradiation
- small increase of signal after full depletion:  
*higher bias voltage* ⇒ *stronger E-field*  
⇒ *lower trapping probability*
- no effect of stitching visible



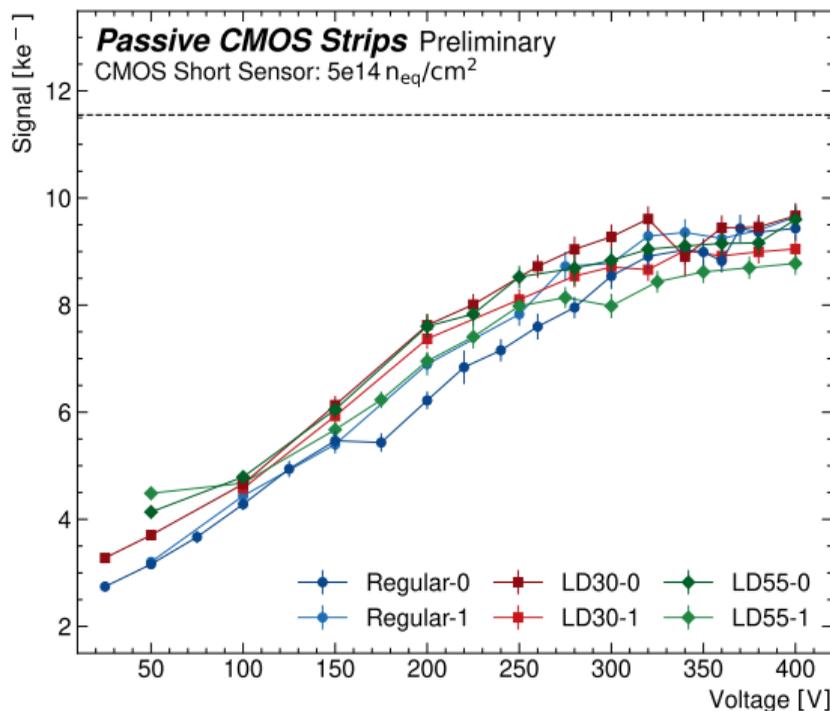
# Charge Collection: Long Sensor

- irradiated up to  $1 \cdot 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2$
- full depletion at  $\sim 90 \text{ V}$
- behaves more expectedly than short sensor
- *LD30/55* show higher signal than *Regular*
- slight signal increase after full depletion
  
- no effect of stitching visible



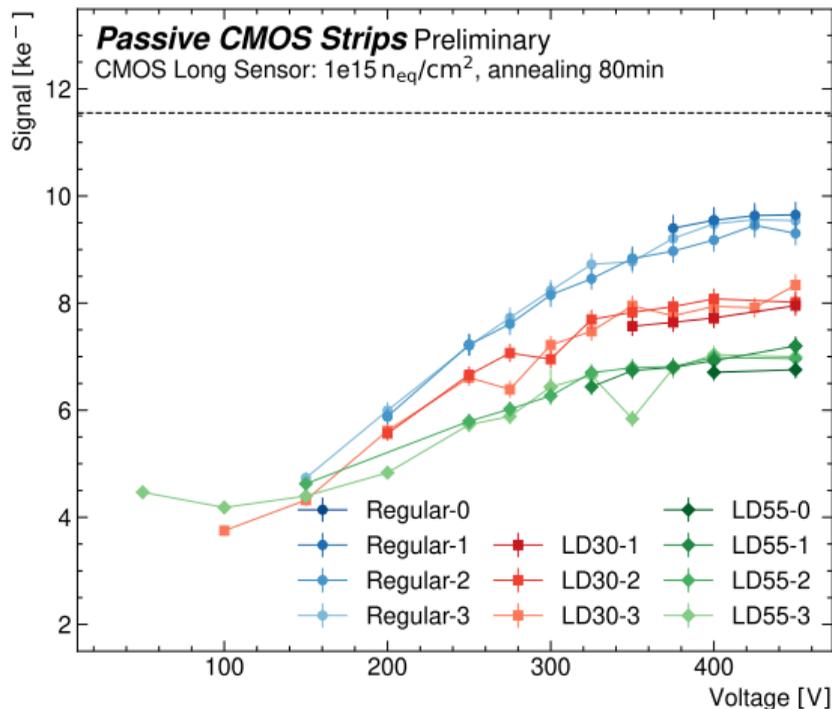
# Charge Collection: Short Sensor

- irradiated up to  $5 \cdot 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2$
- full depletion at  $\sim 300 \text{ V}$
- increase of signal after full depletion
- *Regular* collects more charge again: *this already happens at  $3 \cdot 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2$*
- *LD30/55* collect more charge than *Regular* at low voltages: *simulations show lower E-field at sensor top and stronger field in bulk*  
 $\Rightarrow$  *lower trapping probability*
- no effect of stitching visible



# Charge Collection: Long Sensor

- irradiated up to  $1 \cdot 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$
- after beneficial annealing of 80 min at  $60^\circ\text{C}$
- *Regular* still reaches  $\sim 10 \text{ ke}^-$
- *LD30/55* significantly lower signal
- no effect of stitching visible



# Conclusion

several unirrad. and irradi. stitched strip sensors have been investigated:

- no effects of stitching observed
- promising radiation hardness

BUT still ongoing investigation:

- unclear systematic errors
  - low charge in unirrad. *LD55* short sensor
  - high charge in irradi. *LD30/55* short sensor
- more sensors need to be measured

outlook:

- even higher fluences ( $\mathcal{O}(10^{17})$  n<sub>eq</sub>/cm<sup>2</sup> for FFC)
- 3<sup>rd</sup> batch: separate *LD30* and *55* sensors
- larger areas (more stitches), more strips
- fully utilise CMOS process and include electronics on substrate



Thank you for your attention!

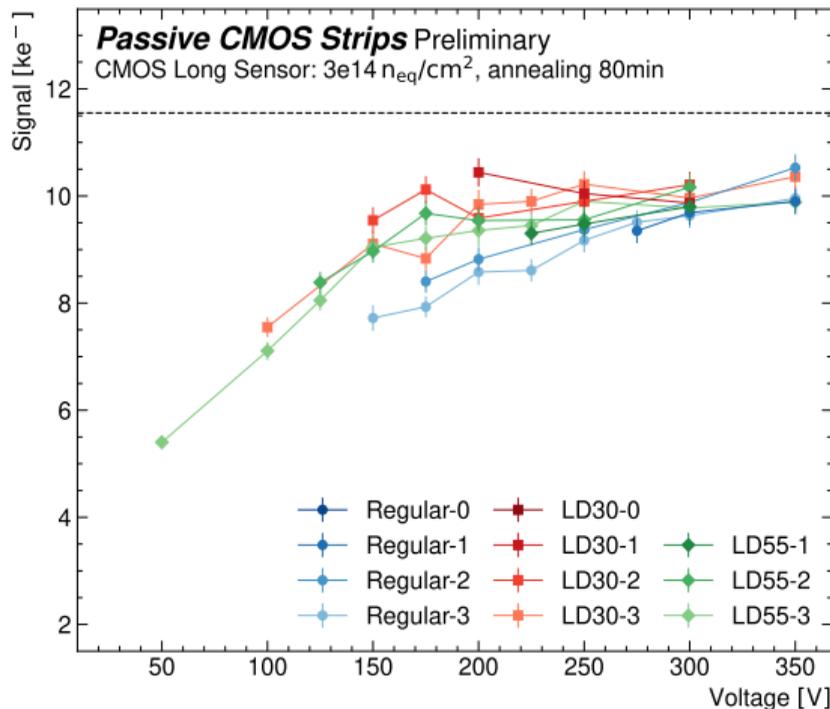


# Back-up

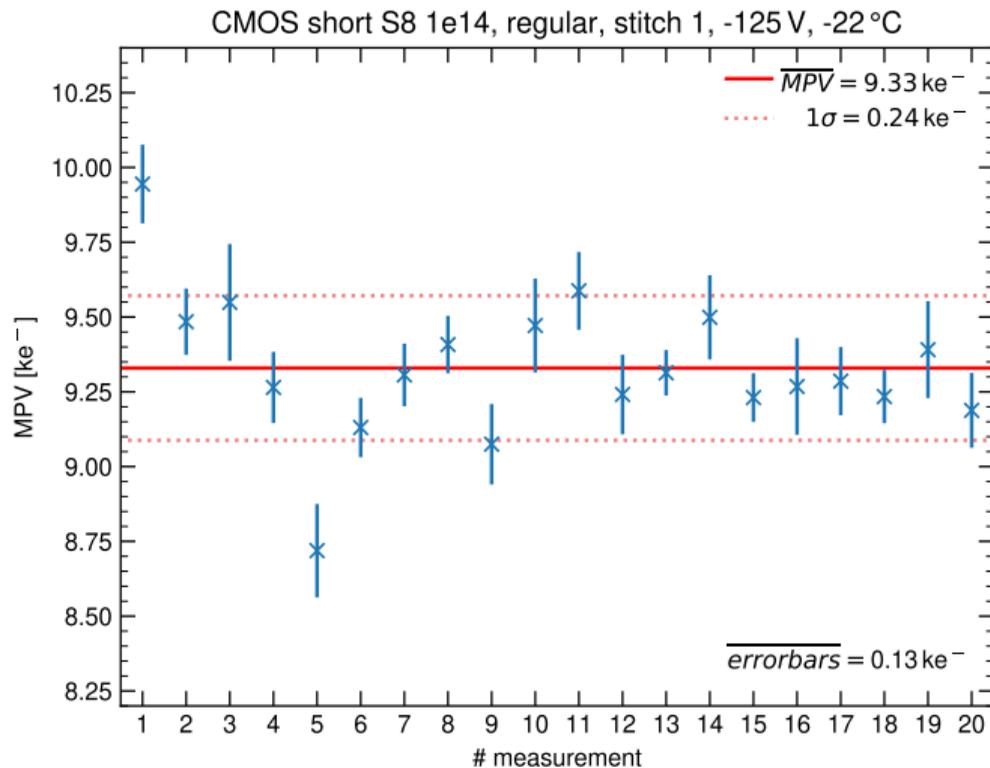


# Charge Collection: Long Sensor

- irradiated up to  $3 \cdot 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2$
- full depletion at  $\sim 160 \text{ V}$
- after beneficial annealing of 80 min at  $60^\circ\text{C}$
- *Regular* collects more charge than lower fluence
- so far promising radiation hardness

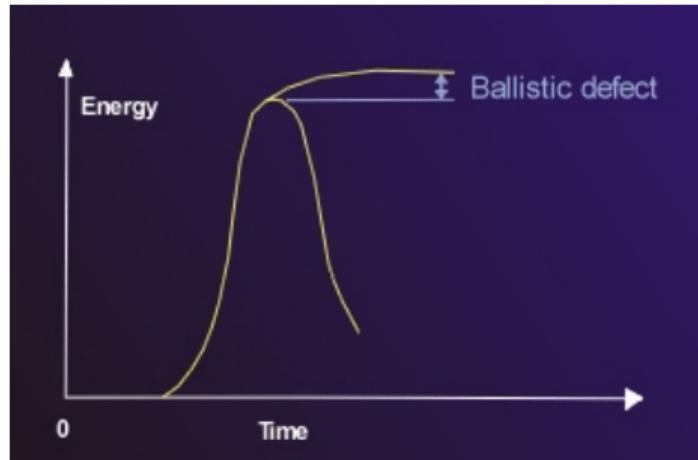


# Statistical Fluctuations



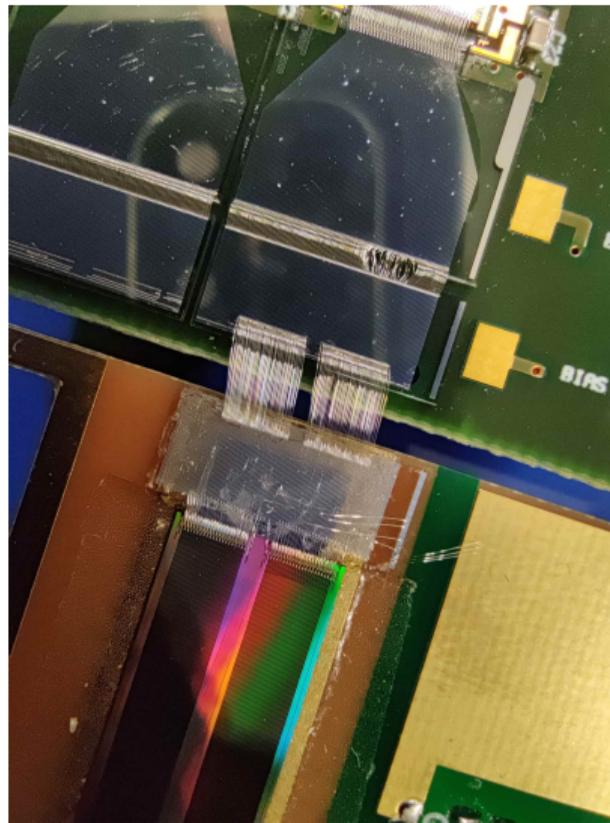
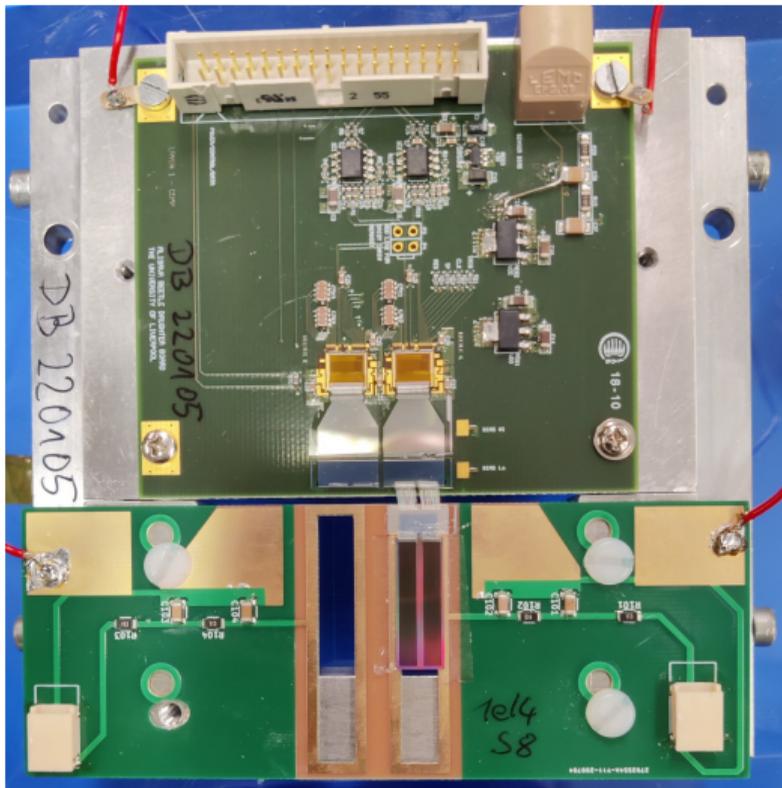
# Ballistic Deficit

- bottom curve shows pulse shape with practical shaping time constant
- upper shows pulse shape with very large shaping time constant  
→ allows full charge collection
- difference in pulse height is called ballistic deficit



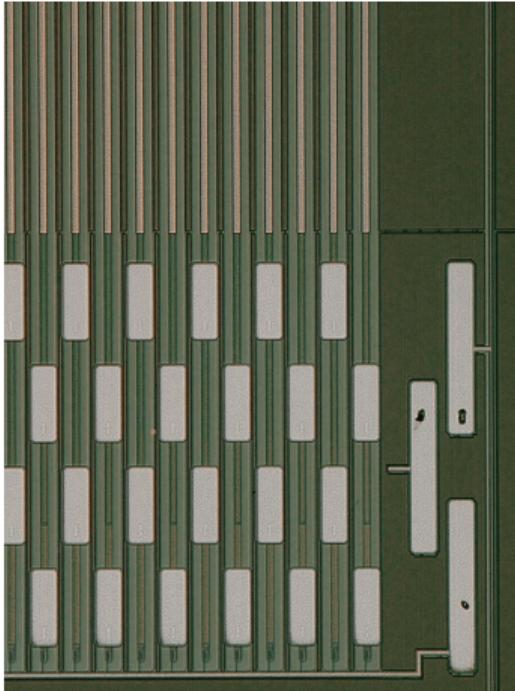
[https://ns.ph.liv.ac.uk/~ajb/radiometrics/glossary/ballistic\\_deficit.html](https://ns.ph.liv.ac.uk/~ajb/radiometrics/glossary/ballistic_deficit.html)

# DB & Bonds

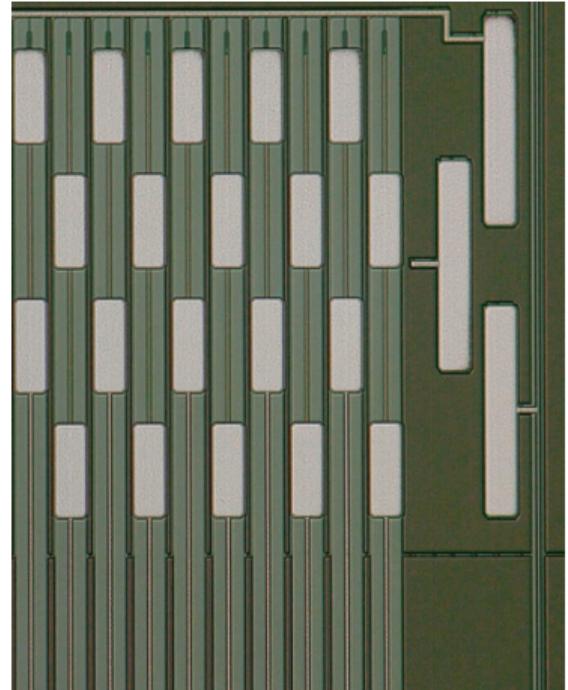


# Sensor Design

regular

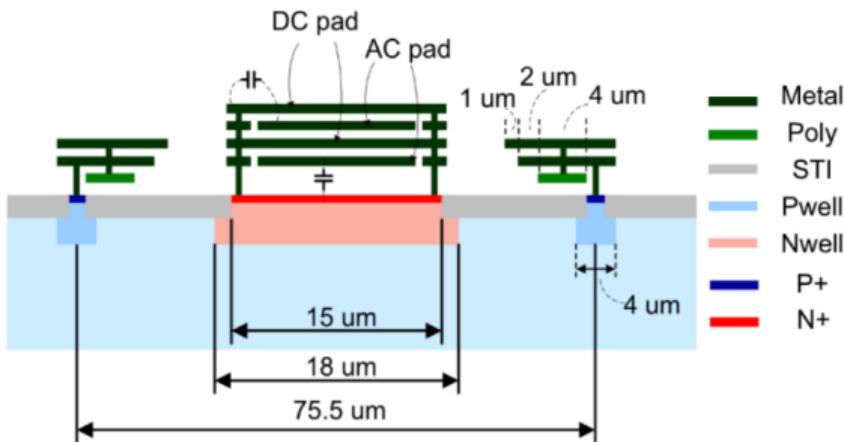


low dose 30/55

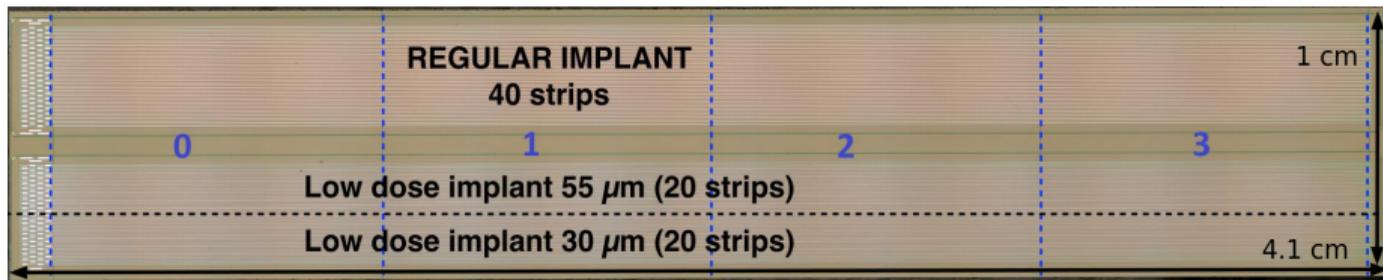
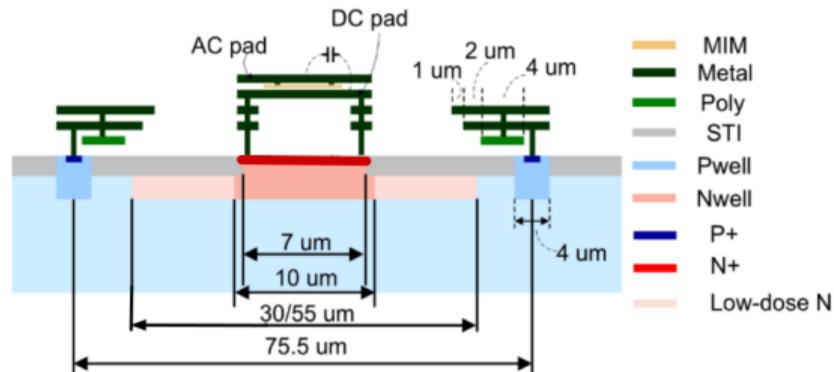


# Sensor Design

regular design

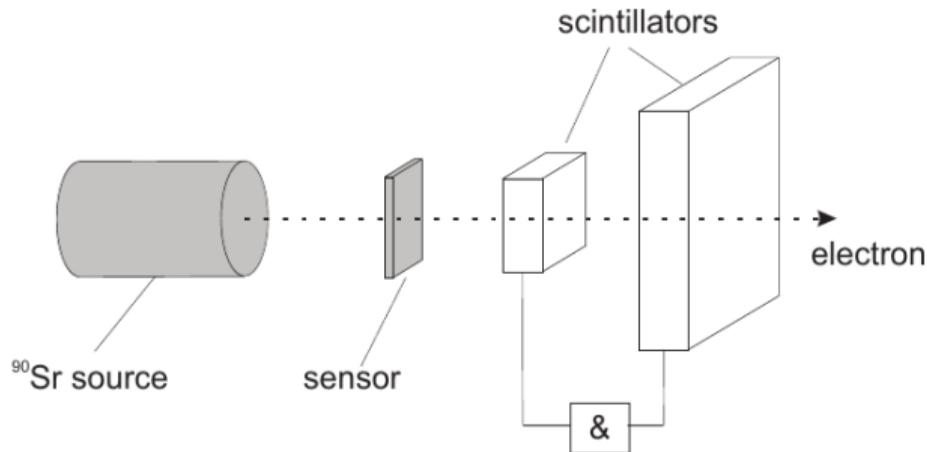


low dose 30/55 design



# ALIBAVA Setup

- $^{90}\text{Sr}$   $\beta$ -decay source
  - gives MIP-like  $e^-$
  - collimated
  - placed in front of different design and stitch regions
- two scintillators
  - trigger in coincidence
  - low energy cut
- sensor on daughterboard with beetle electronics
  - inside freezer, additional liquid nitrogen cooling possible
  - external motherboard for further signal processing and communication with software
  - signal distribution: Landau-Gauss fit to determine MPV



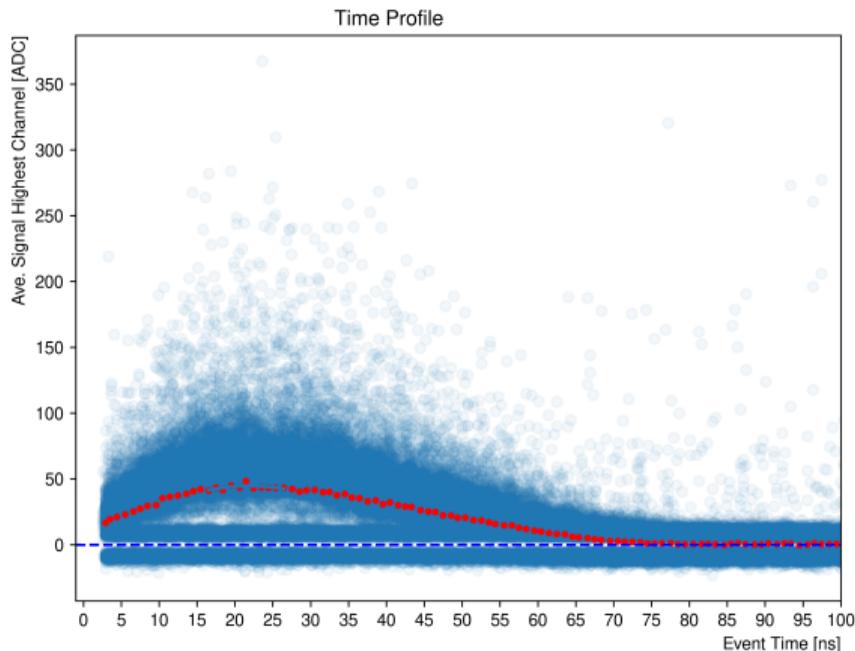
# ALIBAVA measurement & analysis

- position source for different sensor design & stitch regions
- pedestal and source run
- motherboard 40 MHz signal sampling (LHC timing, 25 ns)
- TDC compares signal sample and trigger times  
→ sort *snapshots* of signals acc. to time
- time cut: bias to smaller charge collected if too long
- seed & neighbour cut → cluster algorithm
- get collected charge from Landau-Gauss signal-fits



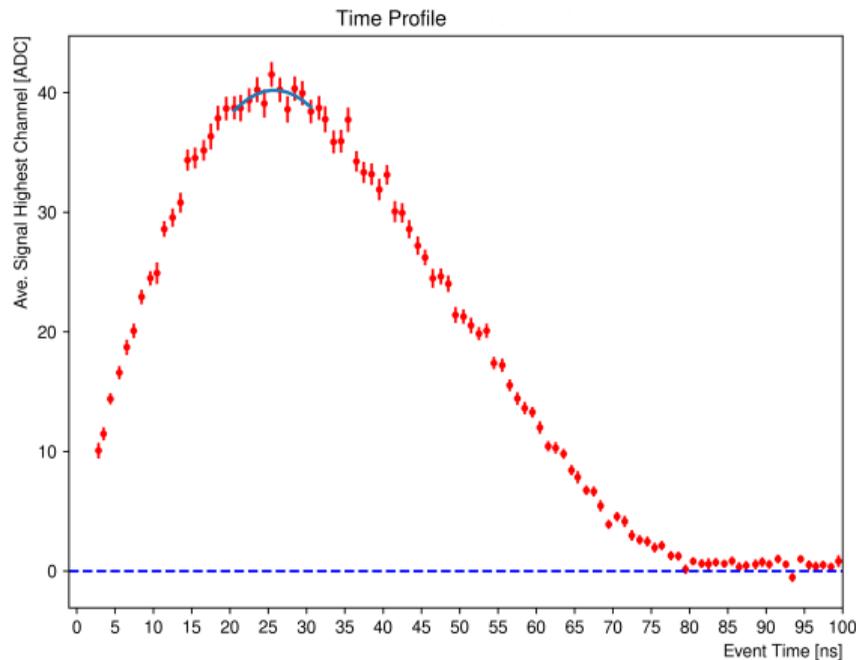
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500V, 10.6°C

